

# APPLIED MICROBIOLOGY AND BIOTECHNOLOGY

## SUPPLEMENTARY MATERIAL FOR:

### Decontaminating Surfaces with Atomized Disinfectants Generated by a Novel Thickness-Mode Lithium Niobate Device

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**Table S1.** The MIC<sub>90</sub> of seven different bacterial isolates (including multi-drug resistant strains) to triethylene glycol (TEG).

<b>Bacterial Strain</b>	<b>MIC<sub>90</sub> (% TEG)</b>
Methicillin Sensitive <i>Staphylococcus aureus</i>	5%
Methicillin Resistant <i>Staphylococcus aureus</i>	5%
Vancomycin Resistant <i>Enterococcus faecium</i>	5%
Extended Spectrum $\beta$ Lactamase Producing <i>Escherichia coli</i>	10%
Multidrug Resistant <i>Pseudomonas aeruginosa</i>	10%
Multidrug Resistant <i>Acinetobacter baumannii</i>	5%
Multidrug Resistant <i>Klebsiella pneumoniae</i> (CRE)	10%